

May 10—July 12, 2019

Program fee: \$4500 +
\$250 application fee

Includes:

- ground transportation and transportation between sites
- housing (homestay!)
- breakfasts and dinners
- health insurance
- cultural excursions
- books
- visa

*Price excludes transatlantic airfare and tuition. Hope Scholarships apply and other funds may be available.



Application Deadline:
February 15

Payment in Full:
April 15

PREREQUISITES:

- RUSS 1001 or equiv
- good academic standing

**Earn 9 Credit Hours
Earn IP Credit**

The School of Modern Languages
613 Cherry Street
Atlanta, GA 30309
www.modlangs.gatech.edu

**Please contact
Dr. Stuart Goldberg
for more information**
sgoldberg@gatech.edu

GT Intensive Summer Russian in Riga & Saint Petersburg (Spring Track)

2020

Study Russian language for **NINE** weeks in Riga, Latvia and St. Petersburg, Russia

- 16+ hrs/week intensive Russian instruction, covering three semesters of Russian. Springboard into third-year Russian next fall!
- Homestays with Russian-speaking families.
The best way to learn Russian!

Cultural program, with excursions including

- Riga Old City
- Gauja national park and Sigulda castle
- St. Petersburg city tour
- the Hermitage
- Peterhof
- Kunstkamera
- Multi-day Moscow trip: Moscow Kremlin, Tretyakov Gallery, Cosmos Museum, Victory Park, Romanov Chambers



Apply today. Spaces are limited.

<http://www.oie.gatech.edu/apply>



1. "Intensive Elementary Russian II" (3 credits, RUSS 1692)

2. "Intensive Intermediate Russian I" (3 credits, RUSS 2691)

3. "Intensive Intermediate Russian II" (3 credits, RUSS 2692)

Courses cover material introduced on-campus in RUSS 1002, 2001, and 2002. Focus on communicative skills and simultaneous development of all modalities (speaking, listening, reading and writing). Survey of fundamentals of Russian grammar, with some advanced topics. Introduction to Russian culture (short stories, songs, poems, film) Surroundings, with opportunities to practice Russian in daily interactions throughout the day and at night in homestays contribute greatly to student progress.